

has been developing and marketing unique proprietary technologies like the PECVD-Mirror technology and ACCT enabling bifacial deposition without vacuum breakage, wafer flipping and manipulations, hence significantly increasing the throughput of the machine and the quality of the devices, providing an unprecedented flexibility in process design. The company has references all around the globe: CSEM & EPFL in Switzerland, Fraunhofer ISE and HZB in Germany, ANU in Australia, the IPVF – France, KAUST in KSA, and SPIC – China.



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